IN THE UNITED STATES PATENT AND TRADEMARK OFFICE h re the application of: Group Art Unit: 3723 Saldana et al. Examiner: Unassigned Application No: 09/748,708 Atty. Docket No: LAM2421 Filed: December 22, 2000 Date: November 11, 2003

For: POLISHING APPARATUS AND METHODS HAVING HIGH PROCESSING WORKLOAD FOR CONTROLLING POLISHING)

PRESSURE APPLIED BY POLISHING HEAD

CERTIFICATE OF MAILING

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INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR §§1.56 AND 1.97(c)

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Commissioner for Patents Alexandria, VA 22313-1450

Dear Sir:

The references listed in the attached PTO Form 1449, copies of which are attached, may be material to examination of the above-identified patent application. Applicants submit these references in compliance with their duty of disclosure pursuant to 37 CFR §§1.56 and 1.97. The Examiner is requested to make these references of official record in this application.

This Information Disclosure Statement (IDS) is not to be construed as a representation that a search has been made, that additional information material to the examination of this application does not exist, or that these references indeed constitute prior art.

This Information Disclosure Statement is believed to be filed before the mailing date of a first Office Action on the merits. Accordingly, it is believed that no fees are due in connection with the filing of this Information Disclosure Statement. However, if it is determined that any fees are due, the Commissioner is hereby authorized to charge such fees to Deposit Account 50-0805 (Order No. LAM2P421).

Respectfully submitted,

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Attorney Docket No. LAM2P421

Attorney Docket No: U.S.

Information Disclosure
Statem nt By Applicant

(Use Several Sheets if Necessary)

Attorney Docket No: U.S.

LAM2P421 10/607,613

Applicant:

Kiermasz et al.

Filing Date: Group:

June 27, 2003 3723

U.S. Patent Documents

Examiner						Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
	Α	4,606,151	08/1986	Heynacher			
	В	4,850,152	07/1989	Heynacher et al.			
	С	5,575,707	11/1996	Talieh et al.			
	D	5,662,518	09/1997	James et al.			
	E	5,762,546	06/1998	James et al.			
	F	5,800,248	09/1998	Pant et al.			
,	G	5,888,120	03/1999	Doran			
	Н	5,888,126	03/1999	Hirose et al.			
	I	5,916,012	06/1999	Pant et al.			
	J	5,931,719	08/1999	Nagahara et al.			
	K	5,961,372	10/1999	Shendon			
	L	5,980,368	11/1999	Chang et al.			
	M	6,102,786	08/2000	Hirose et al.			
	N	6,126,527	10/2000	Kao et al.			
	0	6,135,858	10/2000	Takahashi			
	Р	6,135,859	10/2000	Tietz			
	Q	6,234,878	05/2001	Moore			

Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or		Sub-	Trans	slation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No
	R	EP0920956	06/1999	EPO			х	
	S	JP03259520	11/1991	JPO				х
, ,	T	JP03259520	11/1991	Patent Abstracts of Japan			х	
	U	EP0881039	12/1998	EPO			х	
-	V	FR2767735	08/1998	French Patent Office				х

Other Documents

Other bocuments						
Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication				
	W					
	X					
	Y					
	Z					
Examiner		Date Considered				

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Form 1449 (Modified) Information Disclosur	Attorney Docket No: LAM2P421 Applicant:	U.S. 10/607,613
Stat ment By Applicant	Kiermasz et al. Filing Date:	Group:
(Use Several Sheets if Necessary)	June 27, 2003	3723

U.S. Patent Documents

Examiner						Sub-	Filing
Initial	No.	Patent No.	Date	Patentee	Class	class	Date
	A2	6,062,959	05/2000	Weldon et al.			
	B2	6,103,628	08/2000	Talieh			
	С						
	D						
	E						
	F						
	G						
	Н						
	J						
	K						

Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or	1.1.	Sub-	Trans	lation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No
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Other Documents

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Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.